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_	APPLICATION NO.	FI	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO	CONFIRMATION NO.	
	10/784,932	(02/25/2004	Kazuo Nakajima	249420US2	249420US2 9577	
	22850	7590	10/24/2006		EXA	MINER	
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	OBLON, SPI 1940 DUKE S	•	CCLELLAND, M.	AIER & NEUSTADT, P.C.	ART UNIT	PAPER NUMBER	
	ALEXANDR		22314		1753		

DATE MAILED: 10/24/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)					
		10/784,932	NAKAJIMA ET AL.					
	Office Action Summary	Examiner	Art Unit					
		Kaj K. Olsen	1753					
	The MAILING DATE of this communication ap			s				
Period fo	• •							
WHI(- Exte after - If NO - Failu Any	ORTENED STATUTORY PERIOD FOR REPL CHEVER IS LONGER, FROM THE MAILING Densions of time may be available under the provisions of 37 CFR 1. SIX (6) MONTHS from the mailing date of this communication. Depend for reply is specified above, the maximum statutory period are to reply within the set or extended period for reply will, by statuting reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATIO 136(a). In no event, however, may a reply be ti will apply and will expire SIX (6) MONTHS from e, cause the application to become ABANDONI	N. imely filed in the mailing date of this commun ED (35 U.S.C. § 133).					
Status								
1) 又	Responsive to communication(s) filed on <u>07 J</u>	luly 2006						
·		s action is non-final.						
3)□	<i>,</i> —		osecution as to the mer	rits is				
,—	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposit	ion of Claims							
4)🖂	Claim(s) <u>1-5,9,11,12 and 15</u> is/are pending in	the application.						
	4a) Of the above claim(s) is/are withdrawn from consideration.							
5)	Claim(s) is/are allowed.							
6)⊠	Claim(s) <u>1-5,9,11,12,15</u> is/are rejected.							
7)	Claim(s) is/are objected to.							
8)[Claim(s) are subject to restriction and/o	or election requirement.						
Applicati	ion Papers							
9)[The specification is objected to by the Examine	er.						
10)	The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11)	11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority ι	ınder 35 U.S.C. § 119							
	2) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:							
	1. Certified copies of the priority document							
	2. Certified copies of the priority document							
	 Copies of the certified copies of the prio application from the International Burea 		ed in this National Stag	е				
* 5	See the attached detailed Office action for a list	• • • • • • • • • • • • • • • • • • • •	ed					
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A44- 1	44.5							
Attachmen 1) 🔯 Notic	t(s) e of References Cited (PTO-892)	Δ\	. (DTO 440)					
	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948)	4)						
3) 🔲 Inform	nation Disclosure Statement(s) (PTO/SB/08) r No(s)/Mail Date	5) 🔲 Notice of Informal F						
rape	TOOLOGINAIN DATE	6)						

DETAILED ACTION

Claim Rejections - 35 USC § 112

1. The examiner is withdrawing outstanding 112 rejections in view of the amendment to claims 5 and 15 and the cancellation of claim 8.

Claim Rejections - 35 USC § 103

- 2. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.
- 3. Claims 1-5, 9, 11, 12, and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nakajima et al (USP 2002/0139416 A1) in view of Saidov et al (Technical Physics Letters, 27, 2001, pp. 319-322) or Chan et al (Materials Letters 14, 1992, pp. 263-267). Both Saidov and Chen are being cited for the first time with this office action.
- 4. Alternatively, claims 1-5, 9, 11, 12, and 15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Saidov or Chan in view of Nakajima.
- 5. With respect to claims 1-3, Nakajima et al prepares the instant multi-element polycrystal of having the instant discrete regions dispersed in a matrix (see paragraphs 0009 to 0021, 0031, 0033, and 0034; and Figures 1A to 1D and 2A to 2D). In particular, it is the Examiner's position that the instant multi-element polycrystals prepared according to the procedure and cooling rate in paragraphs 0033 and 0034 and resultant microscopic distributions in Figures 1A to 1D and textures seen in respective Figures 2A to 2D inherently meet the claimed limitation that X1 < X < X2.

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With respect to the now claimed relationship that $X \le 0.1$, Nakajima discloses only the 6. broadly defined range of X between 0 and 1. For the purpose of examination (and in view of Applicant's filed declaration), the examiner will interpret this recitation as not having sufficient specificity to render obvious alone the particular use of X ≤ 0.1 . However, the use of $Si_{1-x}Ge_X$ structures having a low X values has been well demonstrated in the solar cell art. Saidov teaches that Si_{1-x}Ge_x structures having low X values (including the specific examples of 0.05 and 0.10) have lower photosensitivity boundaries in comparison with the X=0.50. See the table on p. 321. Chan teaches that low X values (including particular examples of X=0.03) are desired for Si₁. xGex structures also give a desired lower photosensitivity boundary (i.e. bandgap reduction) and also allows for thicker grown strained layers. See p. 263, first paragraph and fig. 1 and 2. It would have been obvious to one of ordinary skill in the art at the time the invention was being made to utilize the claimed low X values, as demonstrated by Saidov and Chan, for the unspecified X values of Nakajima so as to arrive at a Si_{1-X}Ge_X polycrystal having reduced bandgaps or and increased strain in comparison with the explicitly demonstrated higher Ge concentration of Nakajima.

- 7. With respect to claim 4, the crystal grains are columnar shape (see Figures 2A to 2D where there are discrete regions three dimensionally dispersed in a matrix (see Figures 2A to 2D). It is the Examiner's position that the matrices in Nakajima et al's Figures 2A to 2D have strain.
- 8. With respect to claim 5, a solar cell is manufactured (see paragraphs 0014, 0019, and 0039).

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9. With respect to claims 9 and 12 (those limitations not covered above), Nakajima et al prepares a multi-element polycrystal, such as one containing Si and Ge, or one containing Ga, In and As in instant claim 9, by a method comprising preparing a melt containing multi elements; and cooling the melt while controlling a cooing rate to obtain a multi-element polycrystal (see paragraphs 0027, 0033, 0034; and claims 12 and 13. The composition of the melt is controlled since one selects the amounts of elements to be melted (see paragraph 0033). It is the Examiner's position that the resulting multi-element polycrystal has the instant discrete regions dispersed in a matrix (see Figures 2A to 2D; paragraphs 0022 to 0028; and paragraph 0033 which exemplifies the method of manufacture).

- 10. With respect to claim 11, Nakajima et al prepares said multi-element polycrystal, Si₁. $_X$ Ge_X by a method comprising preparing a melt containing multi elements; and cooling the melt while controlling a cooing rate melt to obtain a multi-element polycrystal (see paragraphs 0027, 0033, 0034; and claims 12 and 13. The composition of the melt is controlled since one selects the amounts of elements to be melted (see paragraph 0033). The resulting multi-element polycrystal has the instant discrete regions dispersed in a matrix (see Figures 2A to 2D; and paragraphs 0022 to 0028). As noted above, it is the Examiner's position that the instant multi-element polycrystals prepared according to the procedure with the cooling rate in paragraphs 0033 and 0034 and resultant microscopic distributions in Figures 1A to 1D and textures seen in respective Figures 2A to 2D inherently meet the claimed limitation that X1 < X < X2.
- 11. With respect to claim 15, a solar cell is manufactured (see paragraphs 0014, 0019, and 0039).

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12. In addition the instant requirement that X1 < X < X2, the instant strain, and the instant discrete regions dispersed in a matrix, would obviously have been present once the multi-element polycrystals prepared according to the procedure in Nakajima et al's paragraph 0033 and 0034 and resultant microscopic distributions in Figures 1A to 1D and textures seen in respective Figures 2A to 2D are prepared and with the particularly suggested compositions of Saidov and Chan.

13. With respect to the claims in the alternative, both Saidov and Chan disclosed the use of multi-element structures for solar cells that have an average $Si_{1-X}Ge_X$ structure with $X \le 0.1$. However, these references did not explicitly disclose all the other elements of the claims. However, Nakajima discloses a process for treating and preparing a $Si_{1-X}Ge_X$ structure that does result in a structure that reads on the defined multi-element of the claims. See the discussion above and in the previous office action of 2-7-2006. This process of Nakajima results in a solar cell that has a longer range of photosensitivity in comparison with uniform compositions, like those of Saidov and Chan. See fig. 3 and paragraphs 0035 and 0036. It would have been obvious to one of ordinary skill in the art at the time the invention was being made to prepare the solar cell of Saidov and Chan in a manner set forth by Nakajima such that the resulting solar cell has an increased photosensitivity and increased efficiency.

Response to Arguments

14. Applicant's arguments filed 7-7-2006 have been fully considered but they are not persuasive. Applicant urges via arguments and declaration that applicant achieved unexpected results with a choice of $X \le 0.1$. That may be true, but it has been well established that a patent

cannot be granted for an applicant's discovery of a result, even though it may be unexpected good, which would have flown logically from the teaching of the prior art. In this particular case, Nakajima discloses a favorable structure and method that overlapped the claimed X range of the applicants, but did not specifically provide any examples in that claimed range. However, the newly cited prior art that one possessing ordinary skill in the art would have motivated to look to the specific composition range of claimed invention to derive favorable properties for the constructed solar cell. See the discussion above.

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kaj Olsen whose telephone number is (571) 272-1344. The examiner can normally be reached on Monday through Friday from 8:00 A.M. to 4:30 P.M..

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam Nguyen, can be reached on 571-272-1342. The fax phone number for the organization where this application or proceeding is assigned is (571) 273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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October 19, 2006

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